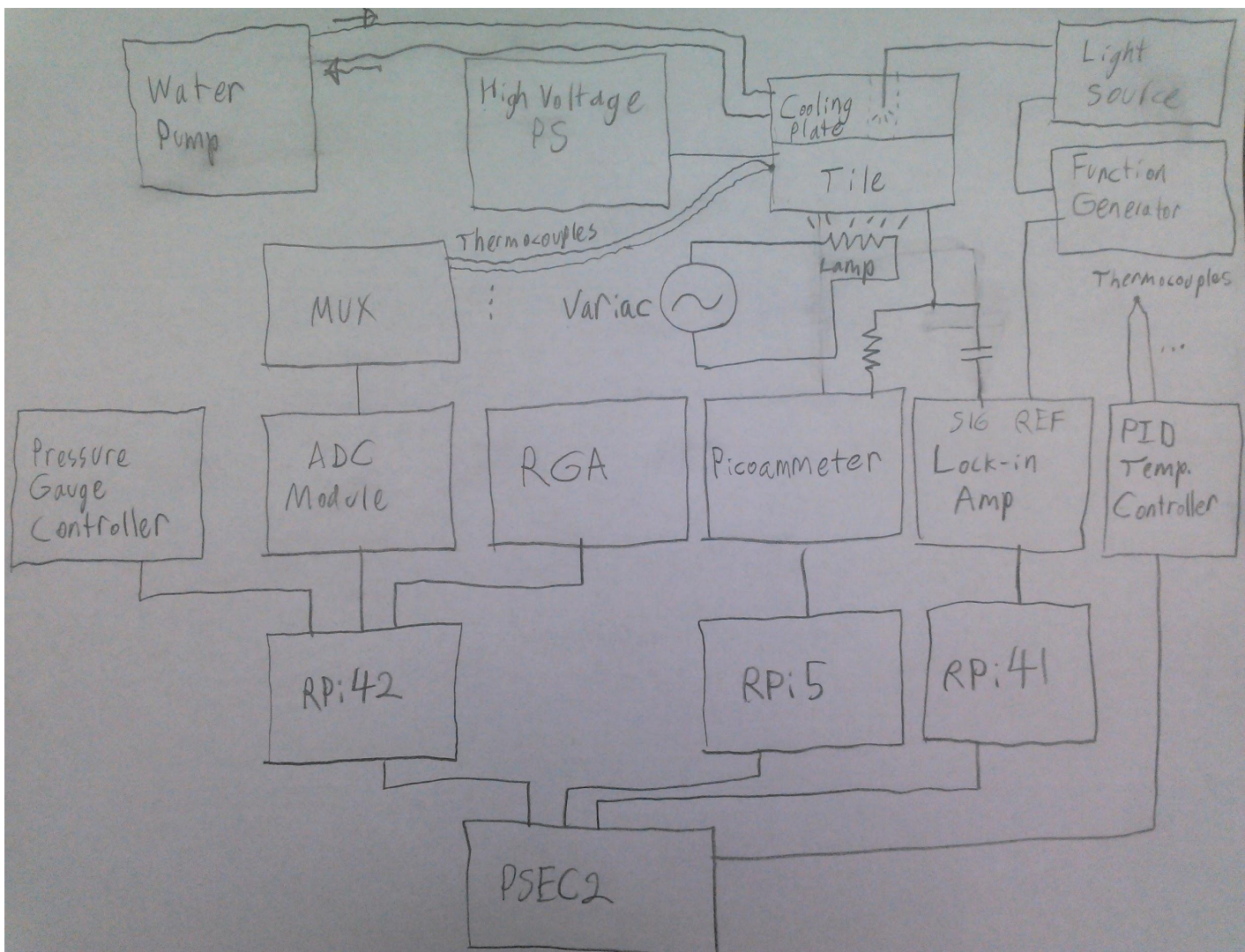
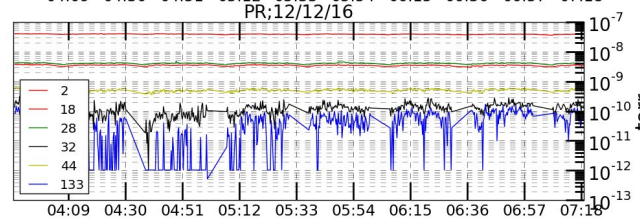
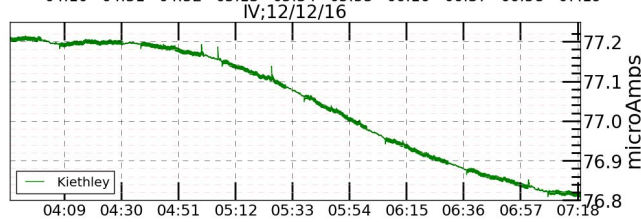
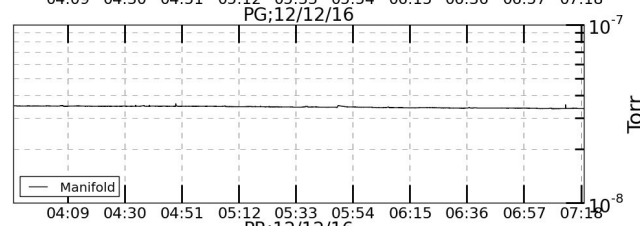
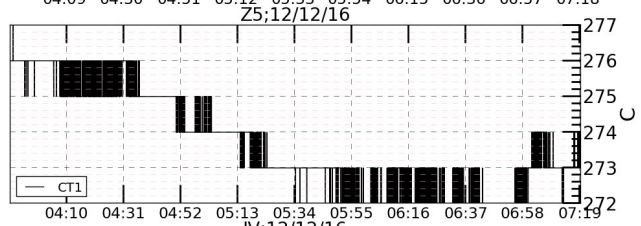
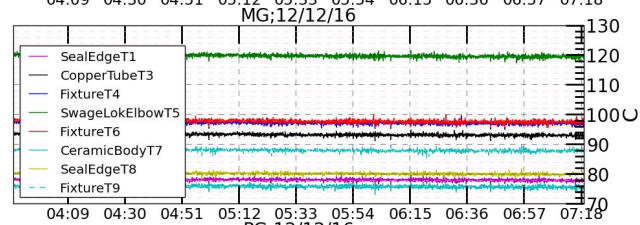
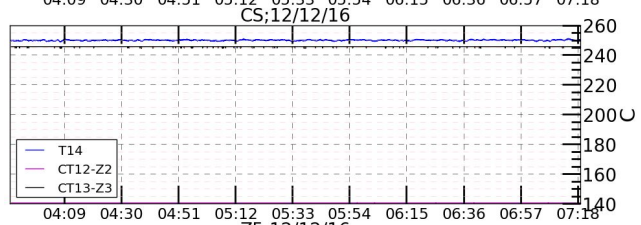
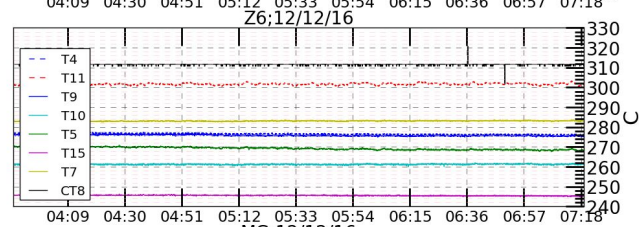
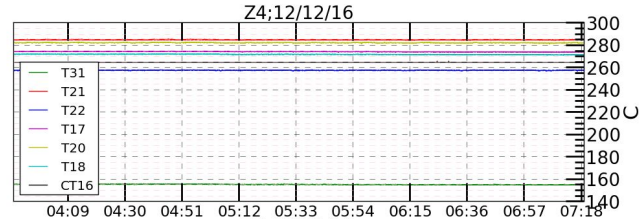
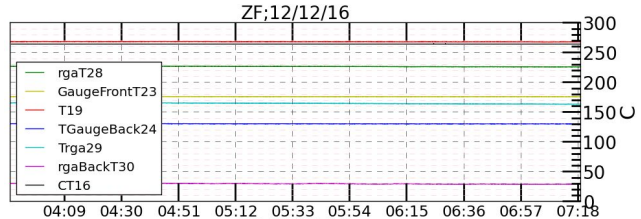
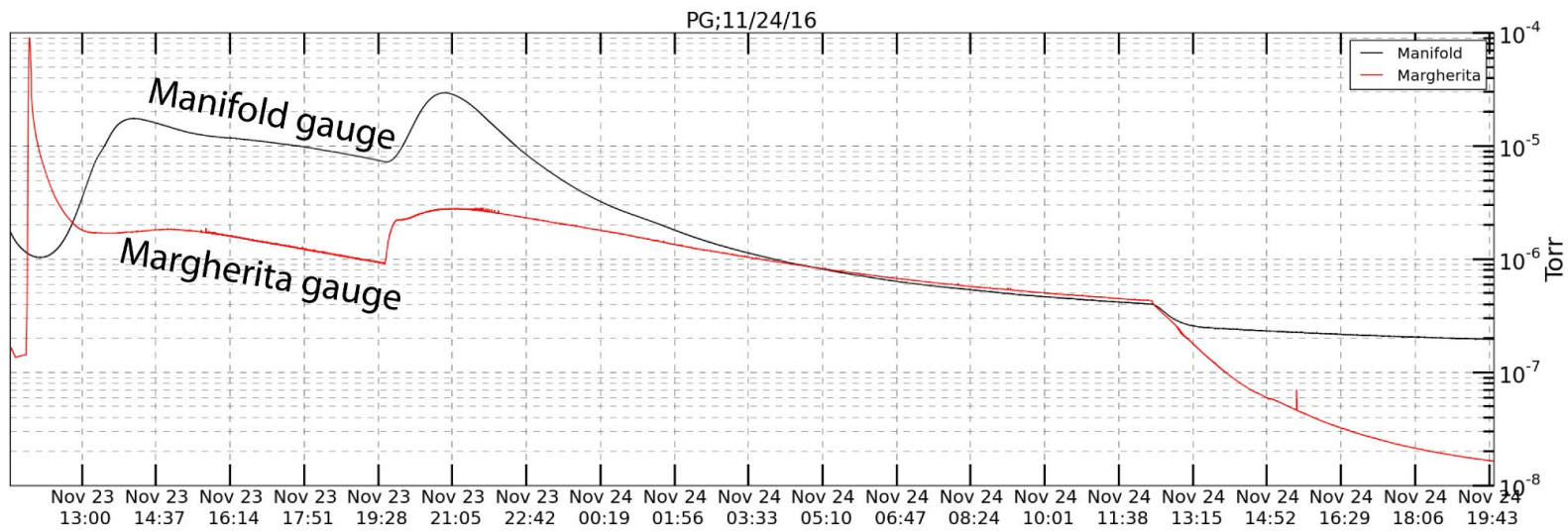
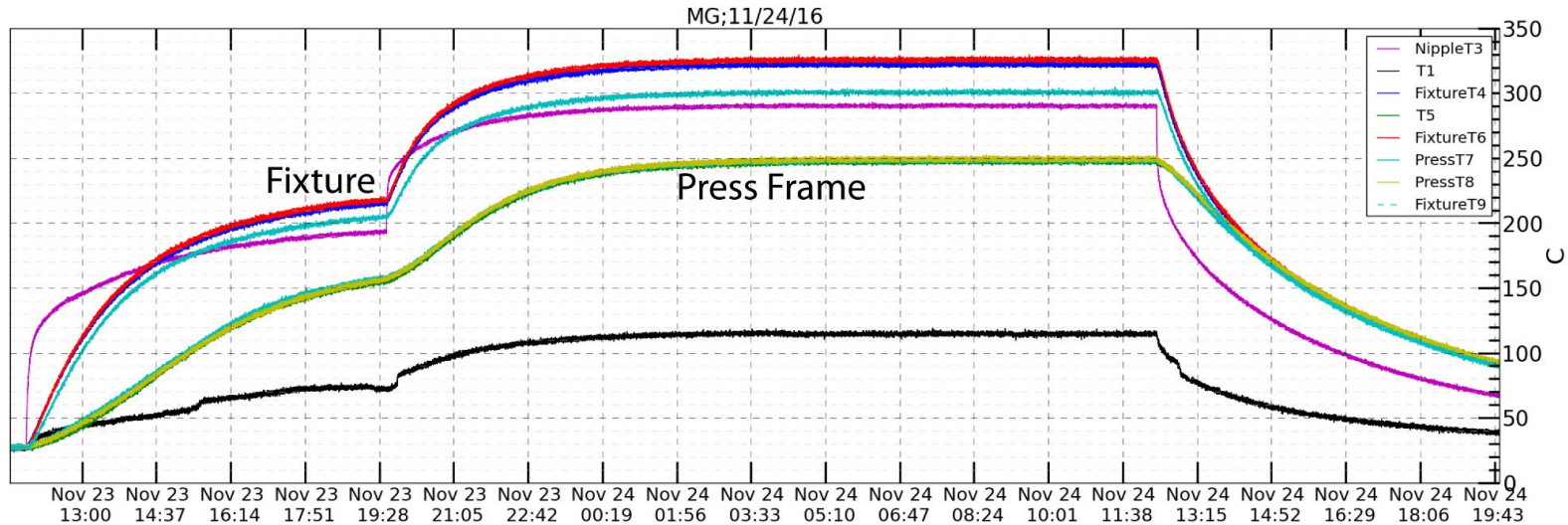
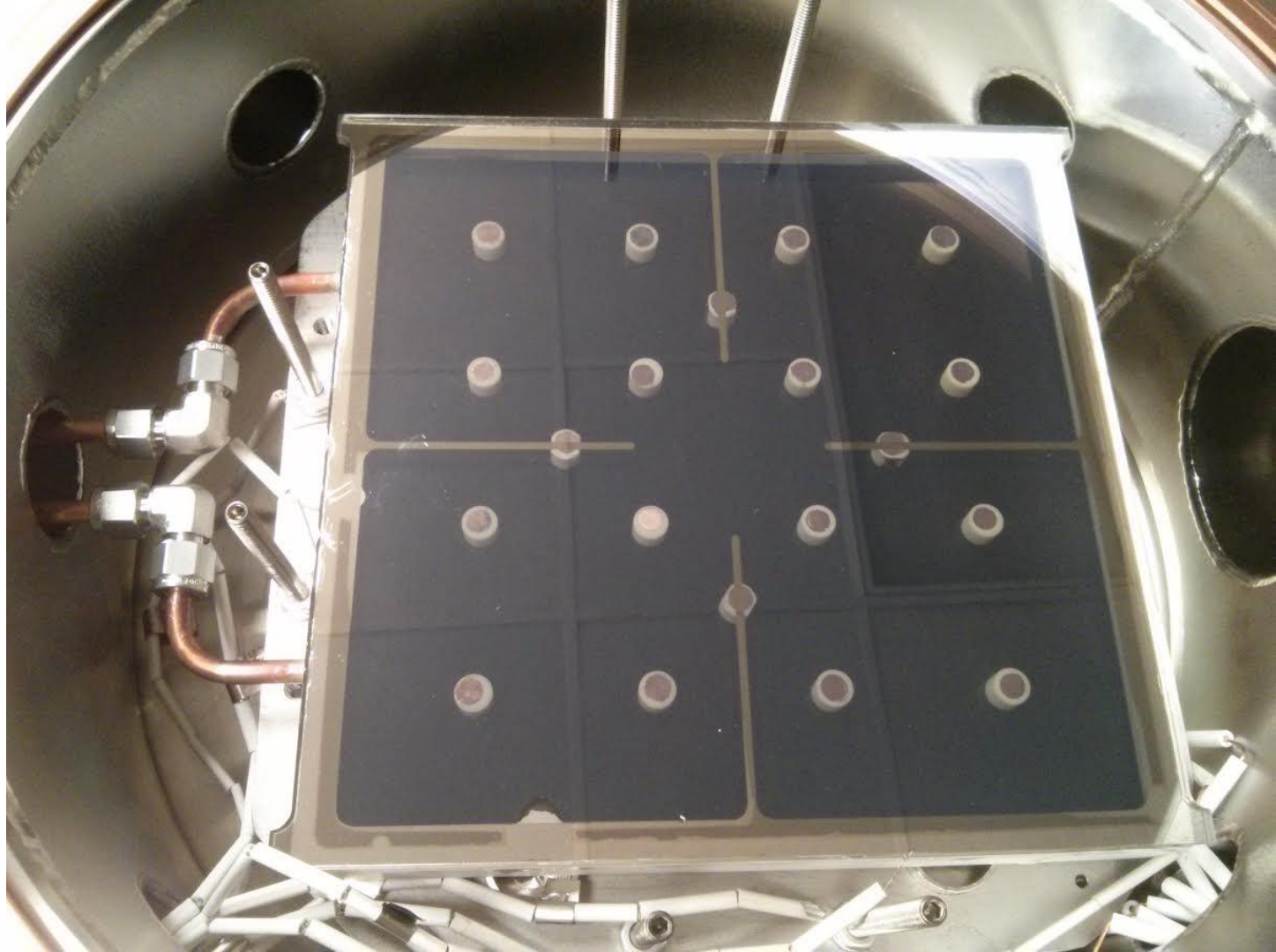


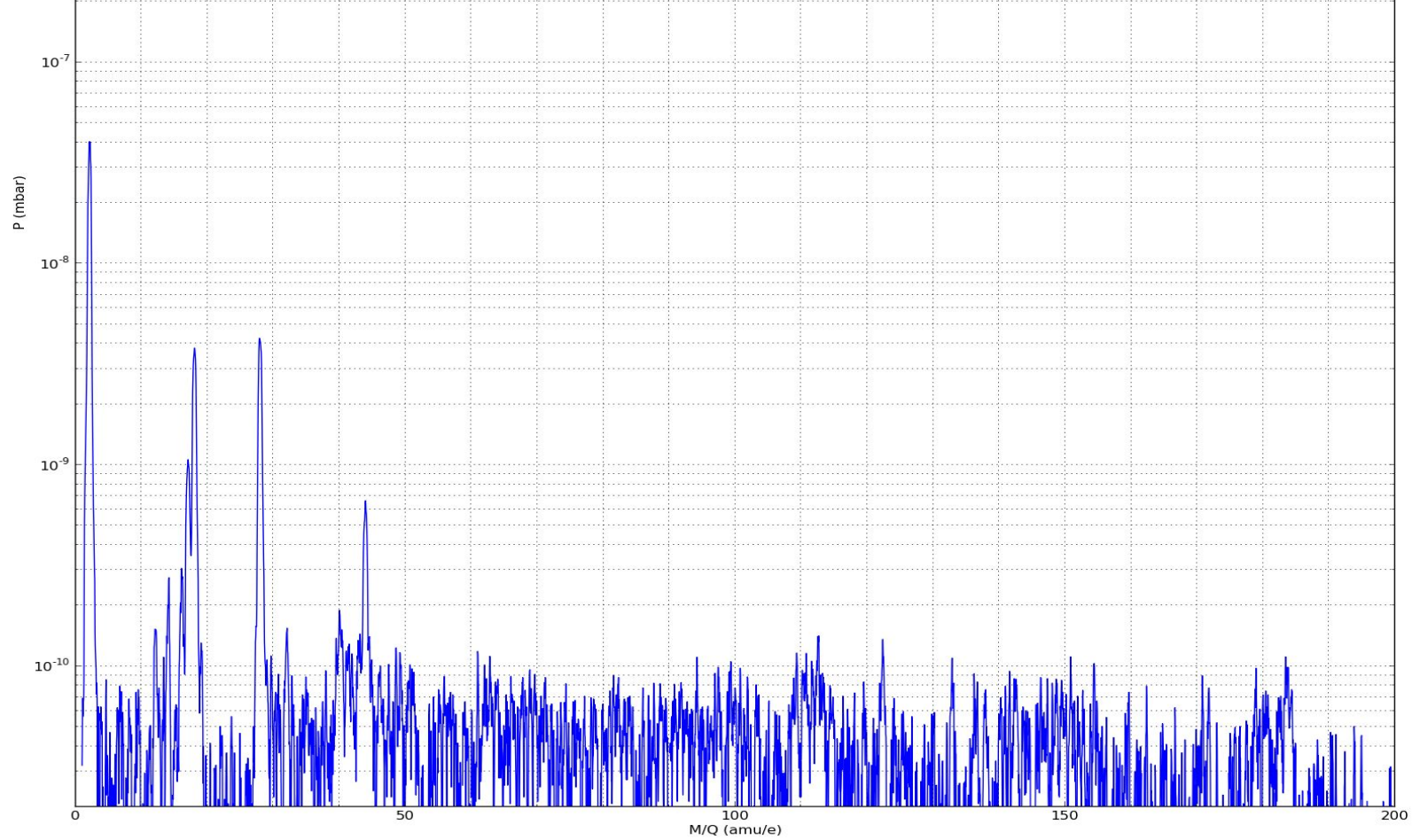
# Instrumentation, Monitoring and Control for the Insitu Process

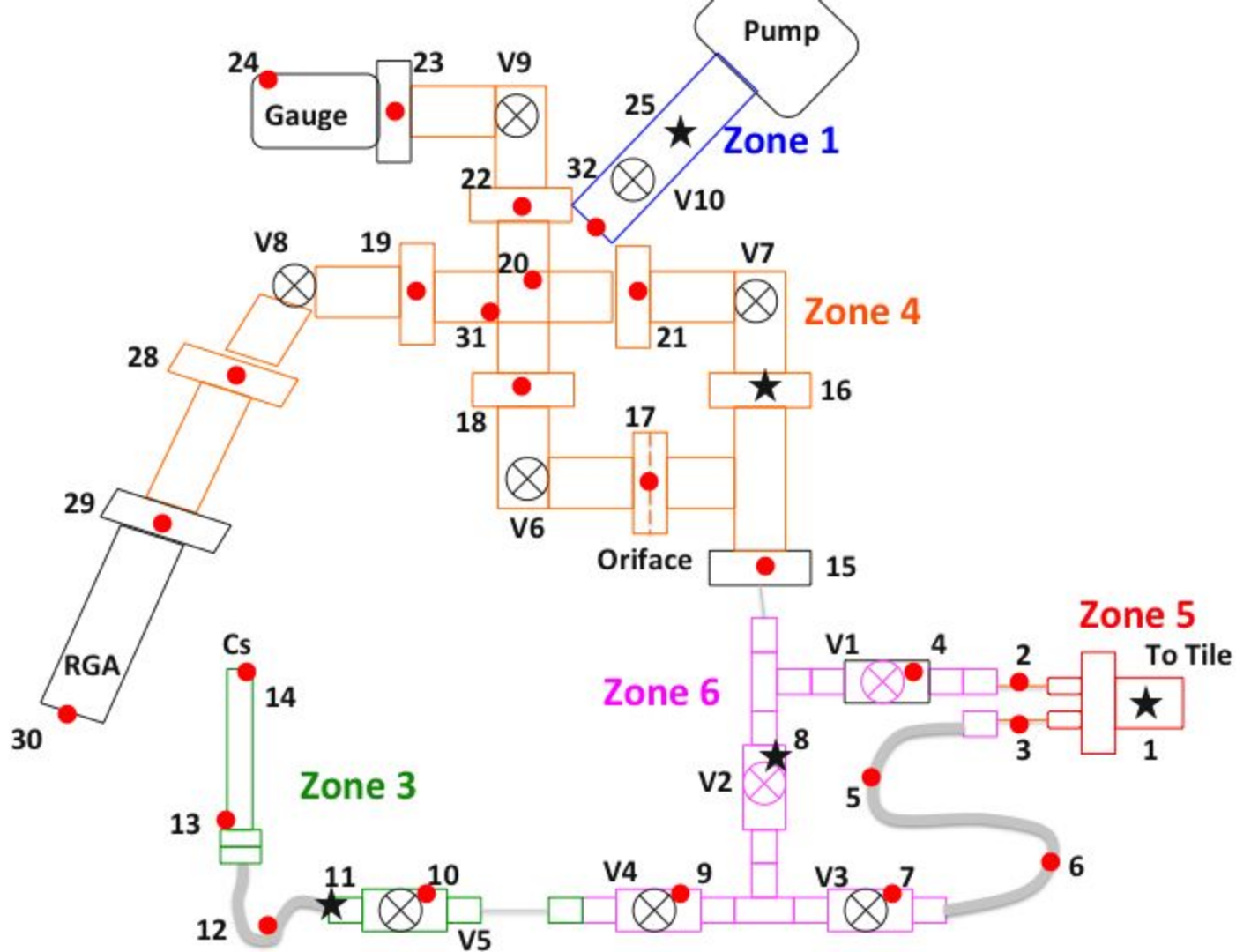




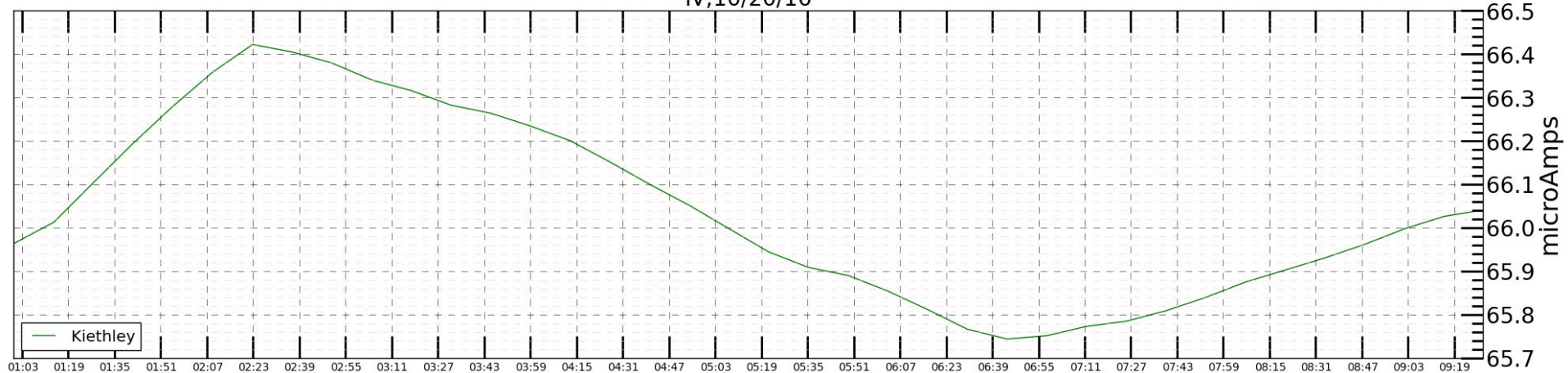




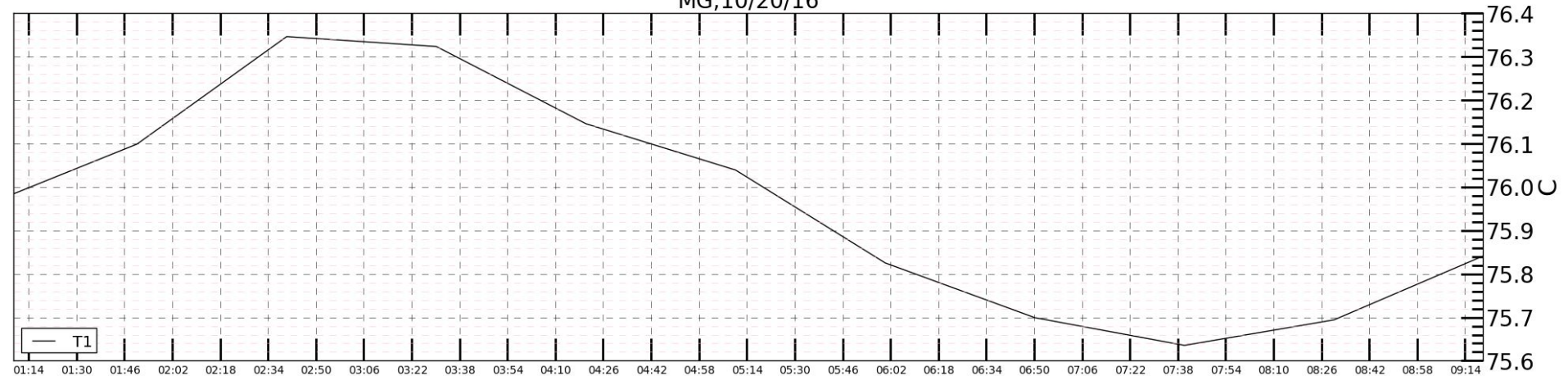


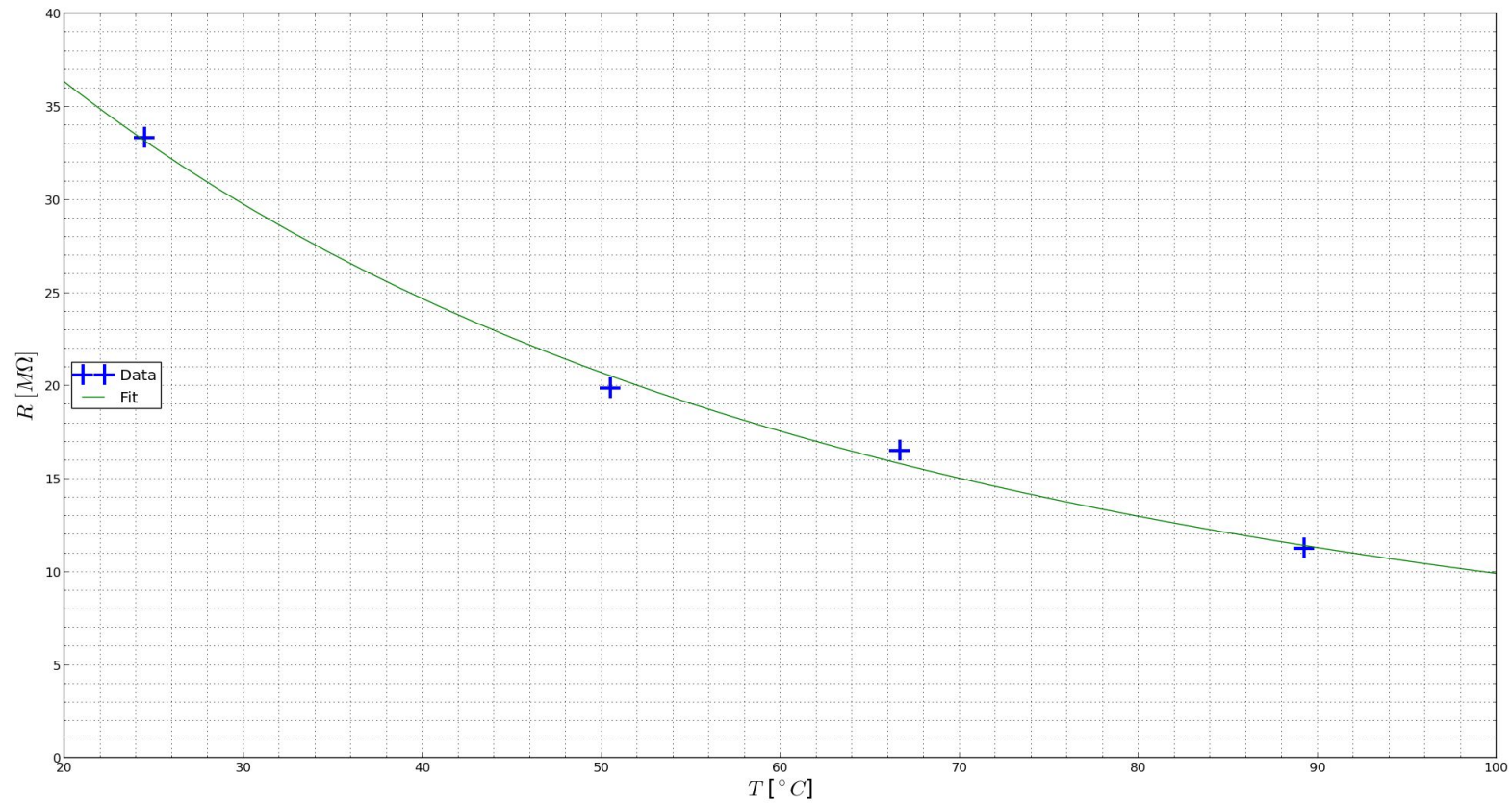


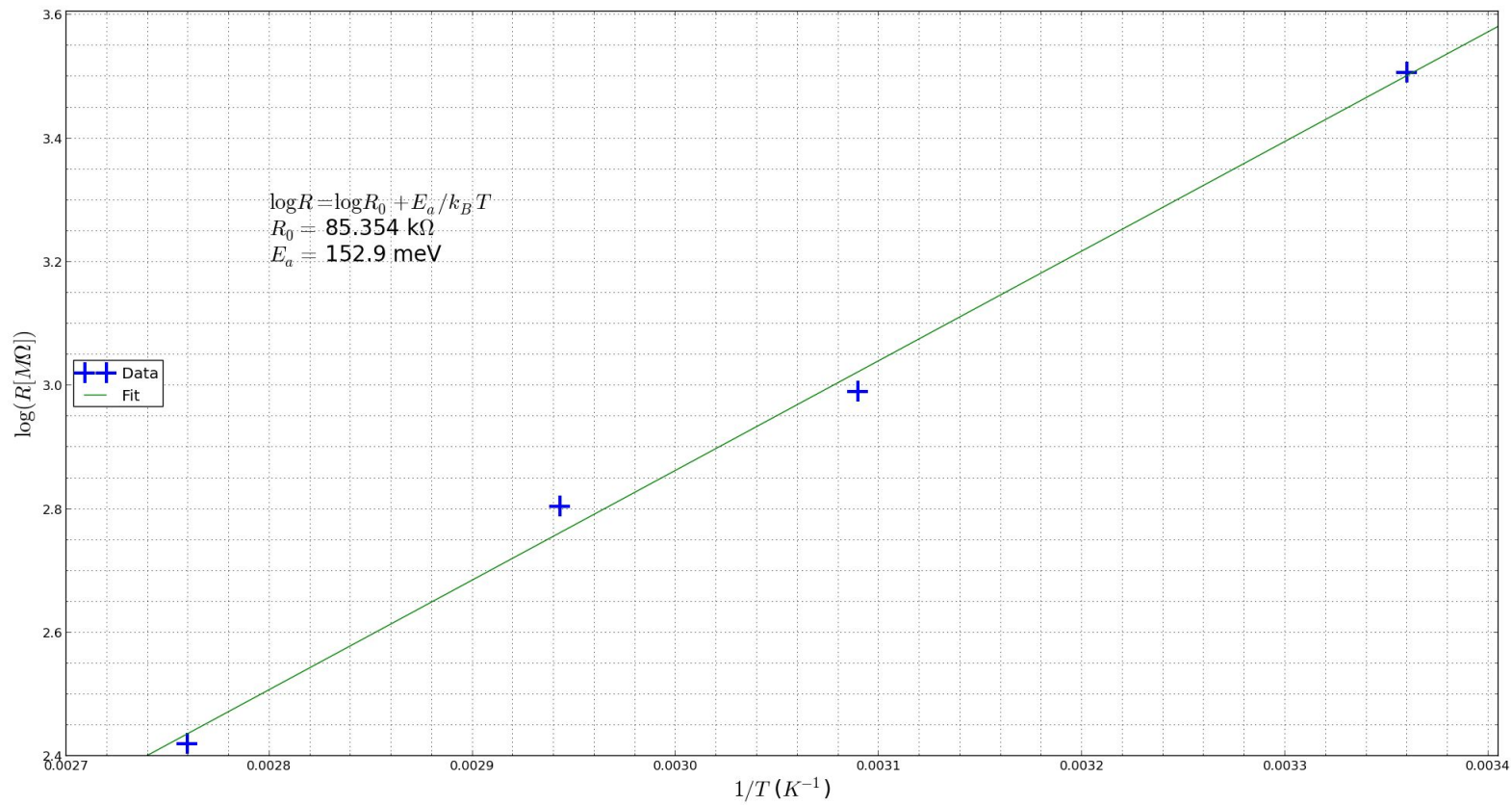
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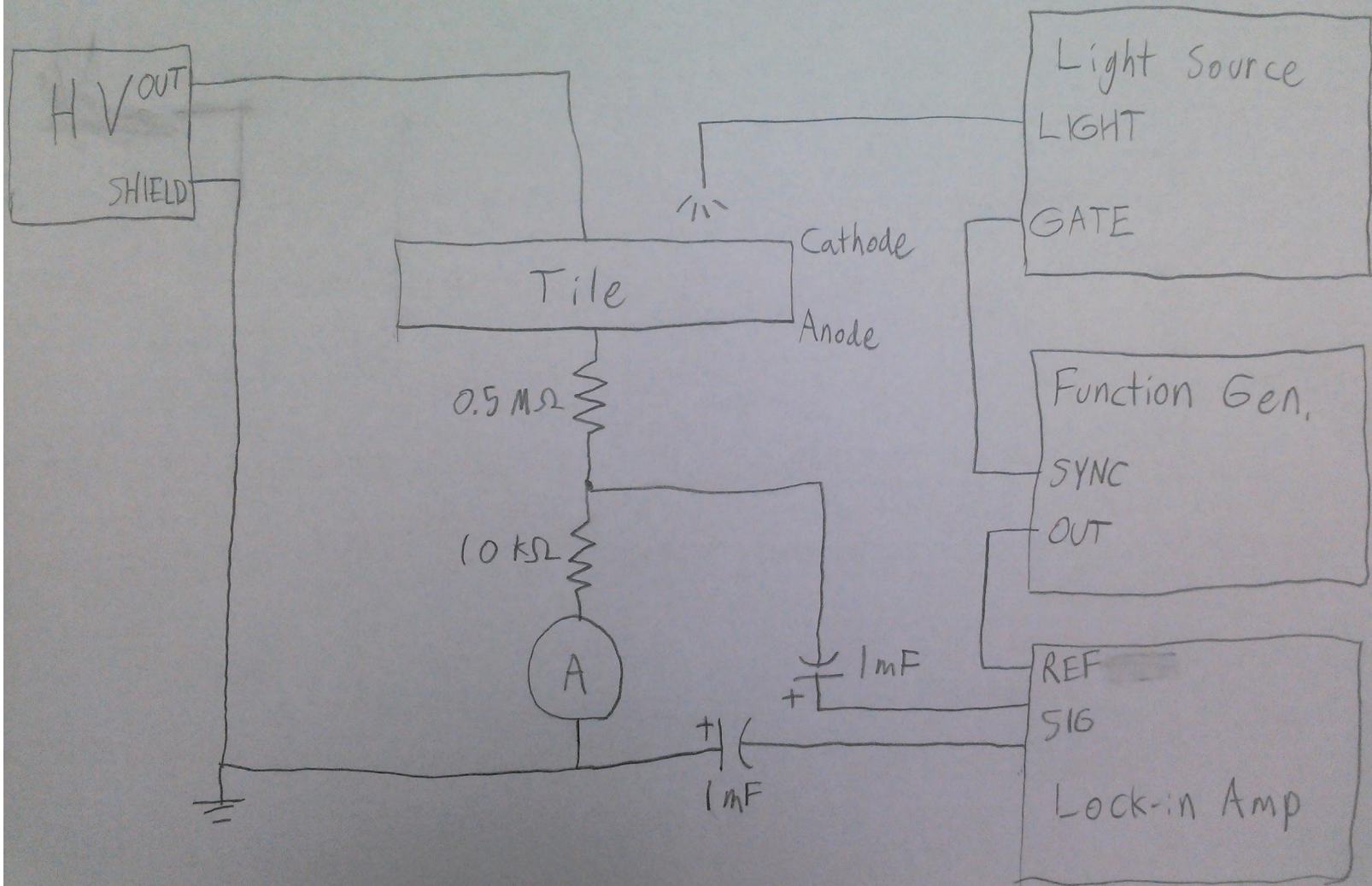


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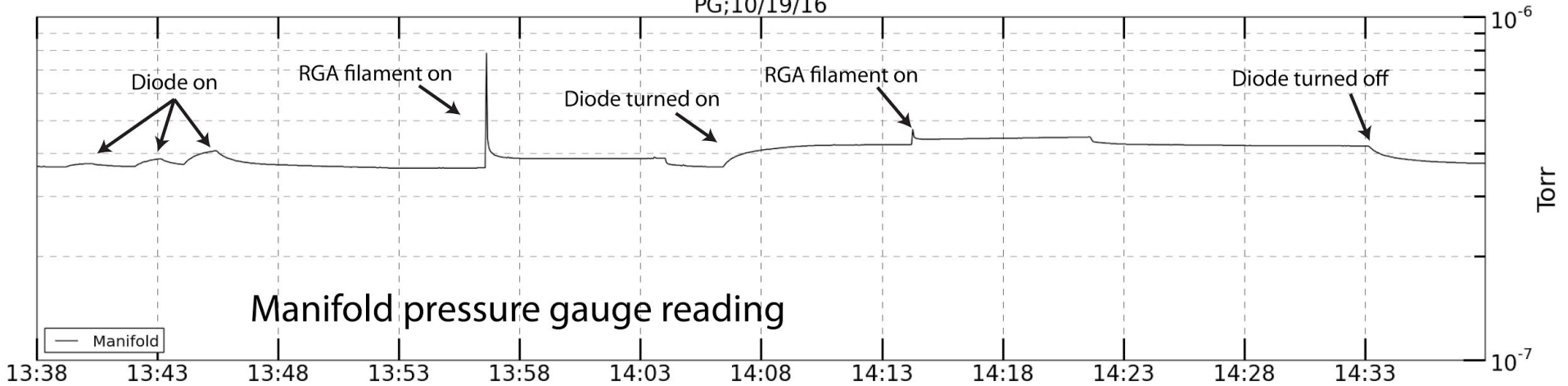




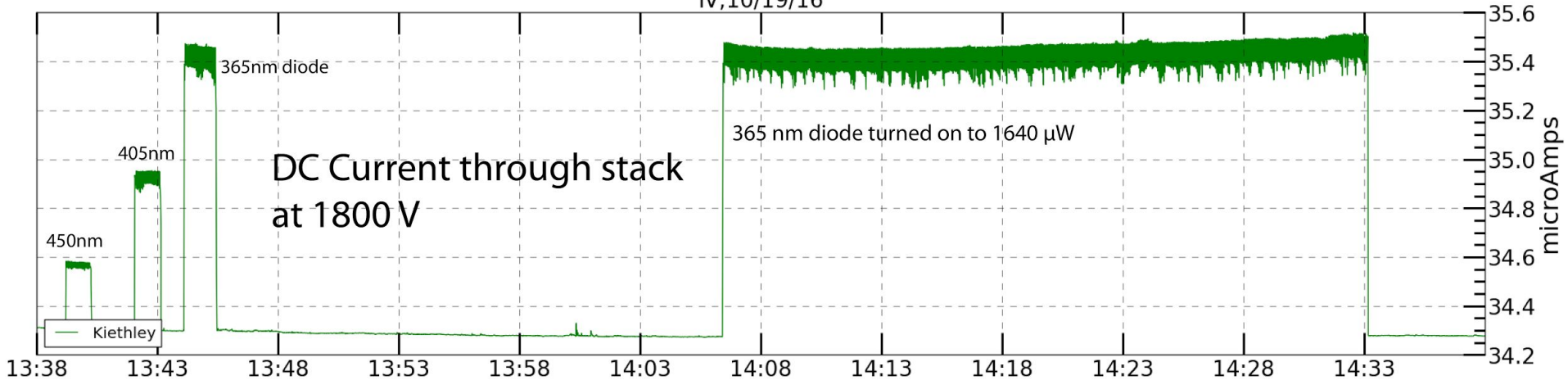




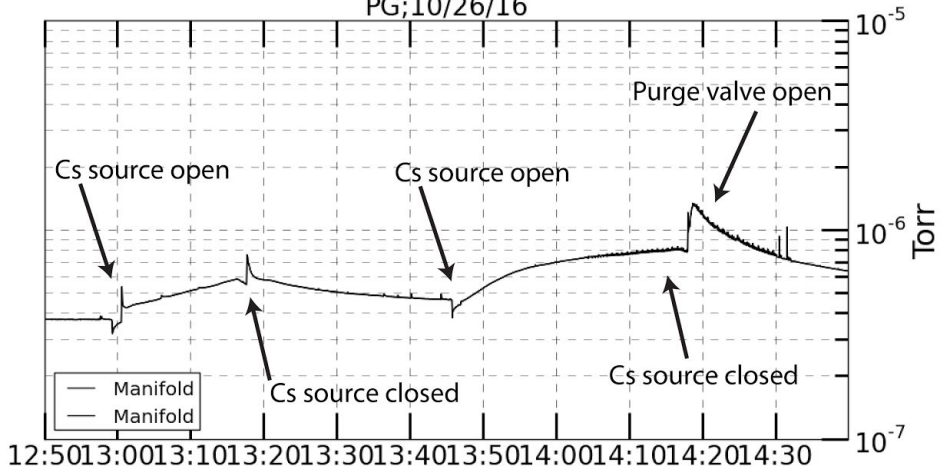
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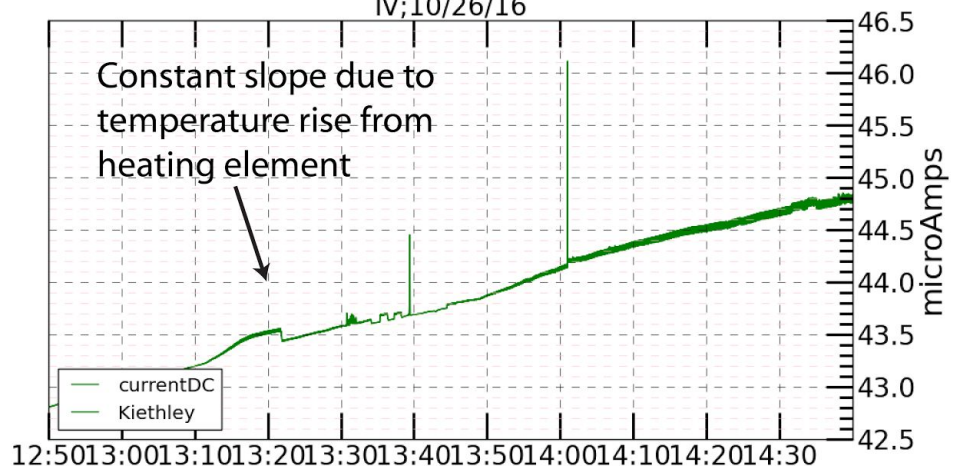
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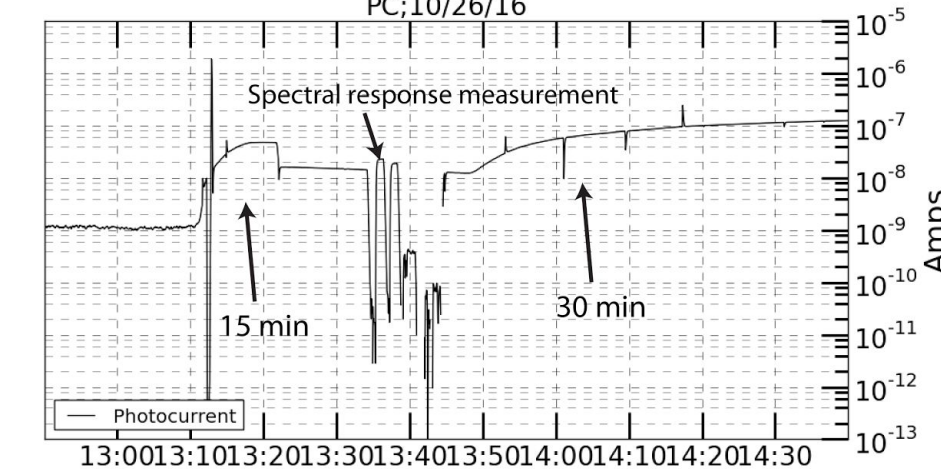
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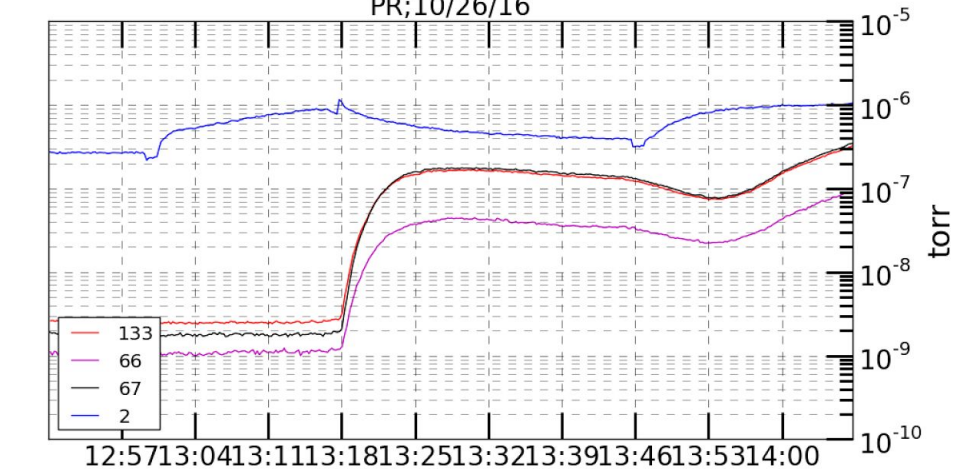
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PC;10/26/16

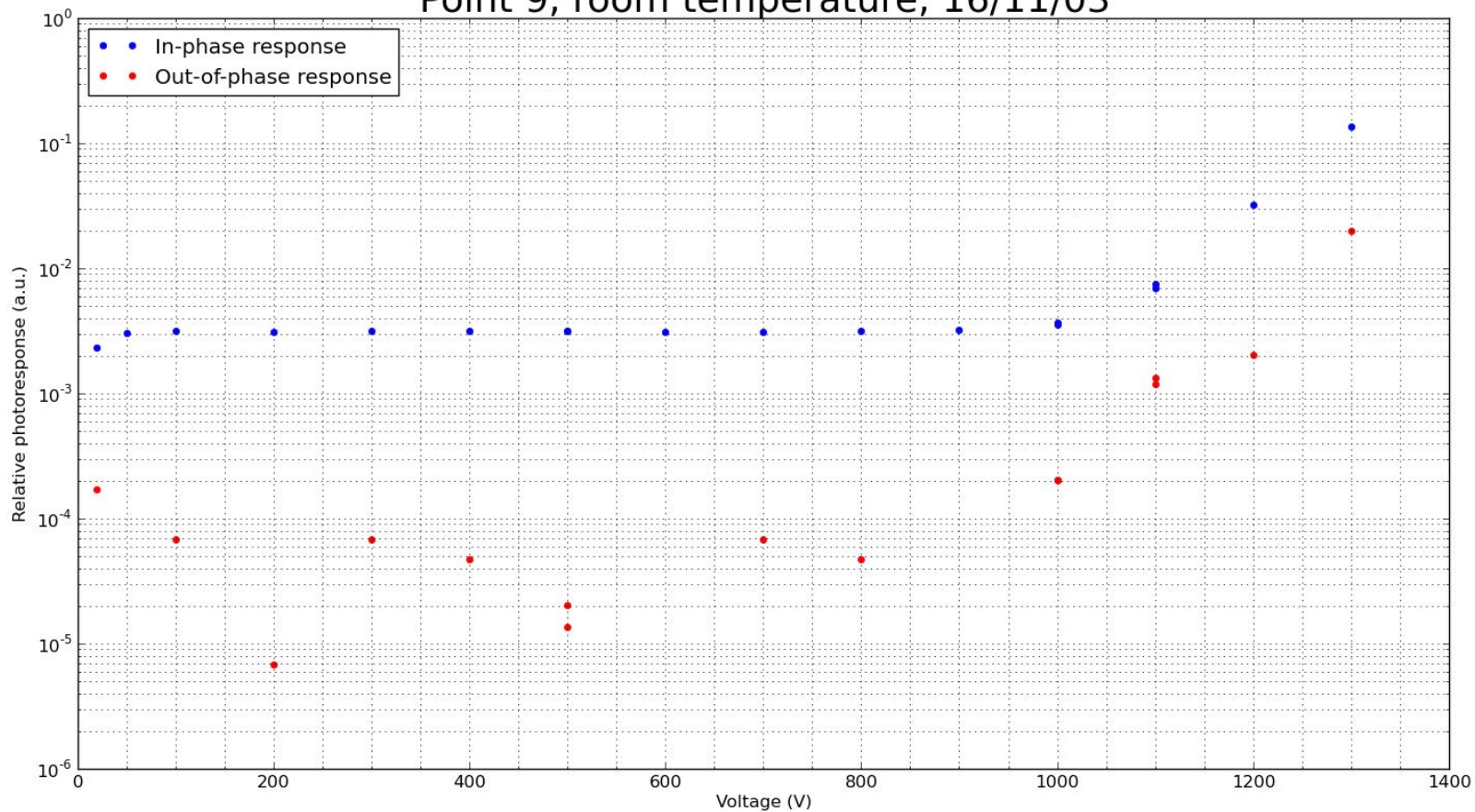


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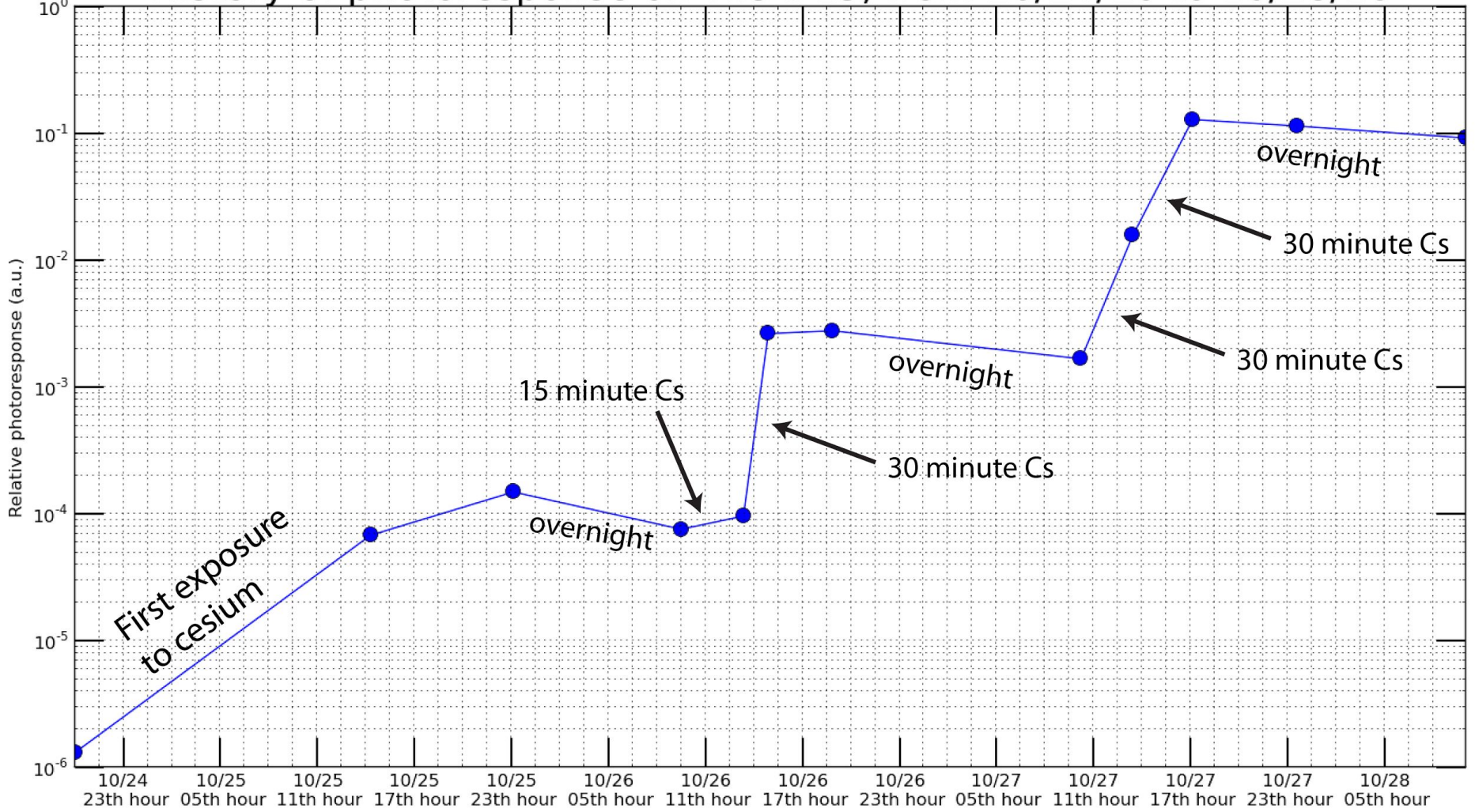


Relative photoresponse vs bias voltage from:

# Point 9, room temperature, 16/11/03



# History of photoresponse on Tile #13, from 10/24/16 to 10/28/16



Relative photoresponse vs wavelength over time

